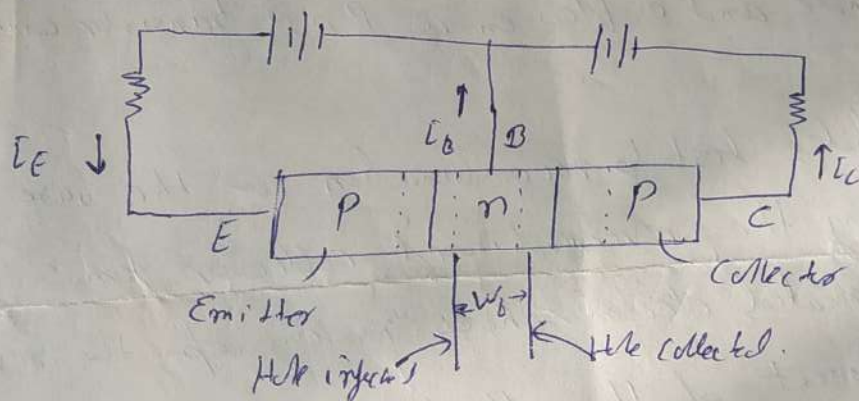


## Bipolar Junction Transistor

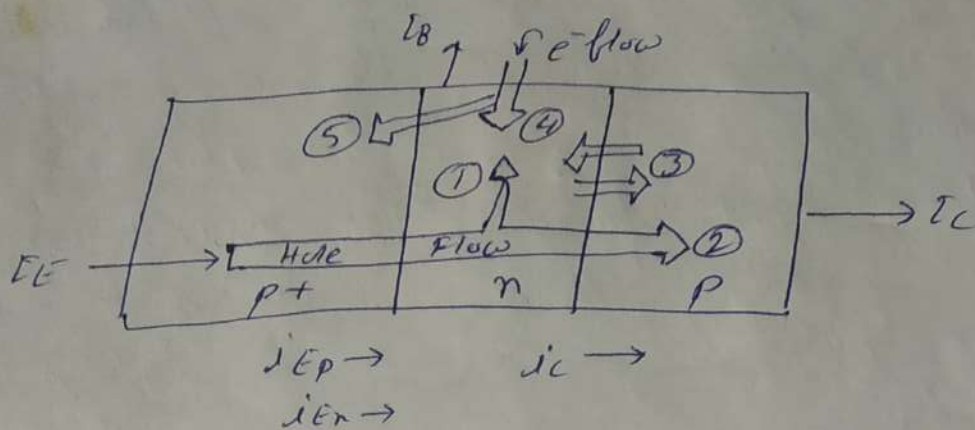
Module 4/ED-①

- The reverse current due to holes being swept from n to P is independent of size of junction,  $E$  field hence is independent of reverse bias.
- Hole current depends upon how often minority holes are generated by C-HP creation within a diffusion length of the junction not upon how fast a particular hole swept across the depletion layer of the field.



- The forward biased junction that injects holes into the central region is called as emitter junction whereas the reverse biased junction that collects the injected holes is the collector junction.
- $P^+$  region which acts as source of injected holes is emitter and  $P$  region into which the holes get swept is called collector.
- For base should be thinner also  $W_B \ll L_p$
- $I_E$  crossing the emitter junction should be composed almost entirely of holes injected into base, rather than  $e^-$  crossing from base to emitter. For this base is lightly doped.





Summary of hole and  $e^-$  flow in a PNP transistor with proper biasing.

- ① Injected holes lost to recombination in the base
- ② Holes reaching the reverse-biased collector junction.
- ③ Thermally generated electron & holes making up the reverse saturation current of the collector junction.
- ④ Electrons supplied by the base contact for recombination with holes.
- ⑤ Electrons injected across the forward biased emitter junction.

The dominant source of base current are  $I_B$  is generally one hundredth of  $I_E$ .

- (i) Recombination in the base.
- (ii) Injection into the emitter region.

## Amplification with BJTs

Mod-4 / ED-2

(2)

$$I_C \propto I_{EP}$$

$$I_C = \beta I_{EP}$$

$\beta \rightarrow$  Base transport factor. Proportionality const.  $\beta$  is simply the fraction of injected holes which make it across the base to the collector.

The emitter injection efficiency  $\gamma = \frac{I_{EP}}{I_{EP} + I_{EN}}$   
 $\swarrow$   $e^-$  component base to emitter

BJT should be near to unity for a good efficient transistor

$$\text{Here } \frac{I_C}{I_E} = \frac{\beta I_{EP}}{I_{EN} + I_{EP}} = \beta \gamma \equiv \alpha$$

$\swarrow$  current transfer factor ratio.

$\alpha$  indicates E to C current amplification.  
 $\alpha < 1$

$$\text{Base current } I_B = I_{EN} + (1 - \beta) I_{EP} \quad \text{neglecting collector saturation current.}$$

$$\begin{aligned} \text{Now } \frac{I_C}{I_B} &= \frac{\beta I_{EP}}{I_{EN} + (1 - \beta) I_{EP}} \\ &= \frac{\beta [I_{EP} / (I_{EN} + I_{EP})]}{1 - \beta [I_{EP} / (I_{EN} + I_{EP})]} = \frac{\beta \gamma}{1 - \beta \gamma} = \frac{\alpha}{1 - \alpha} = \beta \end{aligned}$$

$\beta \rightarrow$  Base to collector current amplification factor.

For a good transistor  $\alpha \Rightarrow 1$  &  $\beta \rightarrow \infty$



Again  $\frac{I_C}{I_B} = \beta = \frac{T_P}{T_d}$

where  $T_d \rightarrow$  transit time, the avg. excess holes spends a time from E to C.

$$T_d \ll T_P$$

minority

Holes at collector hole d the gr can be

center

- A

(i)

(ii)